

CORRECTION
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Correction: Dipolar vinyl sulfur fluorescent dyes. Synthesis and photophysics of sulfide, sulfoxide and sulfone based D- π -A compounds

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Correction for 'Dipolar vinyl sulfur fluorescent dyes. Synthesis and photophysics of sulfide, sulfoxide and sulfone based D- π -A compounds' by Matias Monçalves *et al.*, RSC Adv., 2017, 7, 8832–8842.

The authors regret that Table 2 was incorrectly formatted in the original manuscript showing two solvent columns. The correct table, with only one solvent column is presented below.

Table 2 Relevant photophysical data of the fluorescence spectra, where λ_{em} is the emission maxima (nm), $\Delta\lambda_{\text{ST}}$ is the Stokes' shift (nm cm^{-1}), $\Delta\lambda_{\text{em}}$ is the solvatochromism in the excited state (nm cm^{-1}) and Φ_{FL} is the fluorescence quantum yield (%)

Dye	Solvent ^a	λ_{em}	$\Delta\lambda_{\text{em}}$	$\Delta\lambda_{\text{ST}}$	Φ_{FL}
P1	DIO	416	36/1915	4371	0.34
	DCM	437		5365	0.22
	EtOH	434		5694	0.32
	MeCN	452		6612	0.46
P3	DIO	450	51/2262	5633	0.27
	DCM	483		6683	0.27
	EtOH	506		7634	0.45
	MeCN	501		7895	0.35
P5	DIO	450	85/3531	6533	0.29
	DCM	508		6493	0.33
	EtOH	524		7371	0.45
	MeCN	535		7975	0.20
P2	DIO	428	13/689	3590	0.26
	DCM	435		4039	0.23
	EtOH	433		4153	0.25
	MeCN	441		4498	0.25
P4	DIO	417	16/886	3643	0.44
	DCM	432		3952	0.48
	EtOH	444		4578	0.32
	MeCN	433		4683	0.16
P6	DIO	430	25/1278	3698	0.47
	DCM	449		4610	0.25
	EtOH	455		5049	0.36
	MeCN	455		5049	0.45

^a DIO = 1,4-dioxane, DCM = dichloromethane, EtOH = ethanol and MeCN = acetonitrile.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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